	Application No.	2,836 WEIMER ET AL.	
Notice of Allowahility	10/612,836		
Notice of Allowability	Examiner	Art Unit	
	Stephen W. Smoot	2813	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	6 (OR REMAINS) CLOSED in) or other appropriate commu RIGHTS. This application is so	this application. If not included nication will be mailed in due of	d ourse. THIS
1. A This communication is responsive to applicant's amendment	<u>ent filed on 12 November 200</u>	<u>4</u> .	
2. ☑ The allowed claim(s) is/are <u>43,45-52 and 55-57</u> .			
3. $igotimes$ The drawings filed on <u>03 July 2003</u> are accepted by the E	xaminer.		
4. ☐ Acknowledgment is made of a claim for foreign priority u a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents hav 2. ☐ Certified copies of the priority documents hav 3. ☐ Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received:	e been received. e been received in Application	n No	on from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDON! THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	' of this communication to file MENT of this application.	a reply complying with the requ	uirements
5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXA ves reason(s) why the oath or	MINER'S AMENDMENT or NO declaration is deficient.	OTICE OF
6. ☐ CORRECTED DRAWINGS (as "replacement sheets") mu (a) ☐ including changes required by the Notice of Draftsper 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	son's Patent Drawing Review 's Amendment / Comment or 1.84(c)) should be written on th	in the Office action of e drawings in the front (not the l	oack) of
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 	osit of BIOLOGICAL MATE FOR THE DEPOSIT OF BIO	RIAL must be submitted. No LOGICAL MATERIAL.	ote the
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview Su Paper No./i /08), 7. Examiner's A 8. Examiner's 9. Other	formal Patent Application (PTO Immary (PTO-413), Mail Date Amendment/Comment Statement of Reasons for Allow	vance

This Office action is in response to applicant's amendment filed on 12 November 2004.

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with David G. Latwesen on 16 December 2004.

2. The application has been amended as follows:

In the Claims:

Cancel claims 53-54; and

In claim 55, line 2, change "nitride-containing" to --oxynitride-containing--.

3. Claims 43, 45-52, 55-57 are allowed.

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4. The following is an examiner's statement of reasons for allowance: Applicant's arguments filed on 12 November 2004 with respect to claim 43, as amended, (see pages 7-9) have been fully considered and are persuasive. Accordingly, claims 43, 45-52, 55-57 are allowed because the prior art of record does not teach or suggest, in combination with the other claim limitations, a method of forming a transistor device that includes the step of depositing a deuterated silicon oxynitride-containing material over a gate stack and over sidewall spacers, wherein the silicon oxynitride-containing material is deposited from at least one deuterated nitrogen compound and from one or more halogenated compounds that do not contain hydrogen isotopes.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stephen W. Smoot whose telephone number is 571-272-1698. The examiner can normally be reached on M-F (8:00 am to 4:30 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead, Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Business Center (EBC) at 866-217-9197 (toll-free).

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

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